



PTO/SB/08A (08-03)

<b>Substitute for form 1449A/PTO</b>  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (use as many sheets as necessary)				<b>Complete if Known</b>	
				Application Number	10/773,950
				Filing Date	February 6, 2004
				First Named Inventor	Takuo Tamura
				Art Unit	2818
				Examiner Name	Dao H. Nguyen
Sheet	1	of	2	Attorney Docket Number	16869S-029220US

U.S. PATENT DOCUMENTS+					
Examiner Initials*	Cite No. <sup>1</sup>	Document Number Number Kind Code <sup>2</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
dh	1	US-6,190,949	02-20-2001	Noguchi et al.	
	2	US-6,150,203	11-21-2000	Yamazaki et al.	
	3	US-5,981,974	11-09-1999	Makita	
	4	US-5,904,550	05-18-1999	Yamaguchi	
dh	5	US-5,882,960	03-16-1999	Zhang et al.	

FOREIGN PATENT DOCUMENTS								
Examiner Initials*	Cite No. <sup>1</sup>	Foreign Patent Document			Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T <sup>2</sup>
		Country Code <sup>3</sup>	Number <sup>4</sup>	Kind Code <sup>5</sup> (if known)				
dh	6	JP	11-195608	A	07-21-1999	Hitachi Ltd.		<input checked="" type="checkbox"/>
dh	7	JP	10-41234	A	02-13-1998	Sony Corp.		<input checked="" type="checkbox"/>
dh	8	EP	0598394	A2	05-25-1994	Tokyo Electron Ltd.		<input checked="" type="checkbox"/>

Examiner Signature		Date Considered	01/14/2005
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. <sup>1</sup> Applicant's unique citation designation number (optional). <sup>2</sup> Kind Codes of U.S. Patent Documents at [www.uspto.gov](http://www.uspto.gov) or MPEP 901.04. <sup>3</sup> Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). <sup>4</sup> For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. <sup>5</sup> Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. <sup>6</sup> Applicant is to place a check mark here if English language Translation is attached.

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PTO/SB/08B (08-03)

<b>Substitute for form 1449B/PTO</b>  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (use as many sheets as necessary)		<b>Complete if Known</b>			
		Application Number	10/773,950		
		Filing Date	February 6, 2004		
		First Named Inventor	Takuo Tamura		
		Art Unit	2818		
		Examiner Name	Dao H. Nguyen		
Sheet	2	of	2	Attorney Docket Number	16869S-029220US

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials *	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
dh	9	KURIYAMA et al. "Lateral Grain Growth of Poly-Si Films with a Specific Orientation by an Excimer Laser Annealing Method," Japanese Journal of Applied Physics December 1993, volume 32, pages 6190-6195 (1993).	
dh	10	KURIYAMA "Excimer laser crystallization of silicon films for AMLCDs," Proceedings of Second International Workshop on Active Matrix Liquid Crystal Displays (AMLCDs '95) September 25-26 1995 Bethlehem, PA (1995).	
dh	11	KURIYAMA et al. "Lateral Grain Growth in the Excimer Laser Crystallization of Poly-Si," Proceedings of the Materials Research Society Symposium November 1993, volume 321, pages 657-662 (1993).	

Examiner Signature		Date Considered	01/14/2005
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<sup>2</sup> Applicant's unique citation designation number (optional). <sup>2</sup> Applicant is to place a check mark here if English language Translation is attached.